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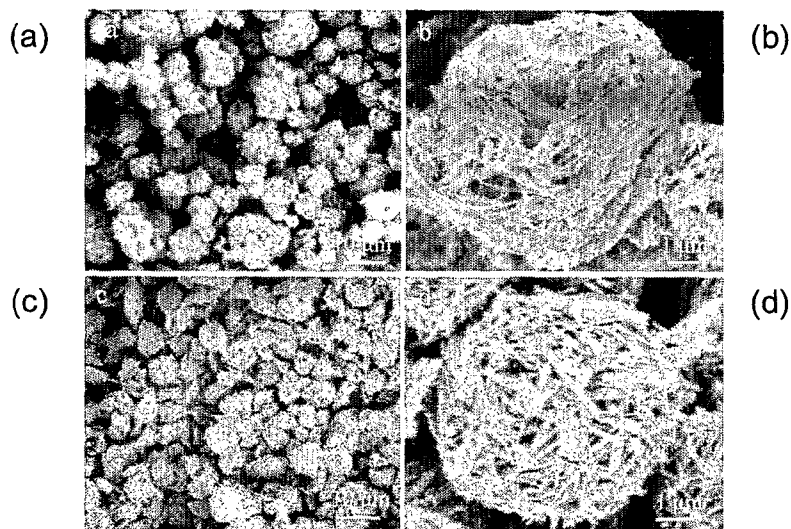
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(54) Title: HOLLOW POROUS MICROSPHERES

FIG.1A



(57) Abstract: The present invention refers to a hollow microsphere having a porous circumferential wall comprised of nanofilaments.

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